

Review Article

Recent Development of Trifluoromethyl Reagents: A Review

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Abstract

Organic molecules having fluorine atom are very important since it increases the lipophilicity that is essential for drug development and additionally strong carbon-fluorine (C-F) bond makes the material unique, especially for material chemistry. Instead of elemental fluorine, recently trifluoromethylated materials (CF₃) have drawn considerable attention in the agrochemical and pharmaceutical industries. In the continuous development of the trifluoromethylated reagents, over the last few decades, some trifluoromethylated reagents have been well developed and the efficiency of these reagents for incorporating CF₃ group on different types of substrates are also studied. In this article, all types of available trifluoromethylated reagents and their effectiveness on suitable substrates are summarized. Additionally, the methods of synthesizing trifluoromethylated substrates are discussed. Finally, the scopes of the development of new reagents after focusing on the shortcomings of the current reagents are also discussed.

Keywords: Nucleophilic; Electrophilic; Free radical; Solvent; Electrochemical.

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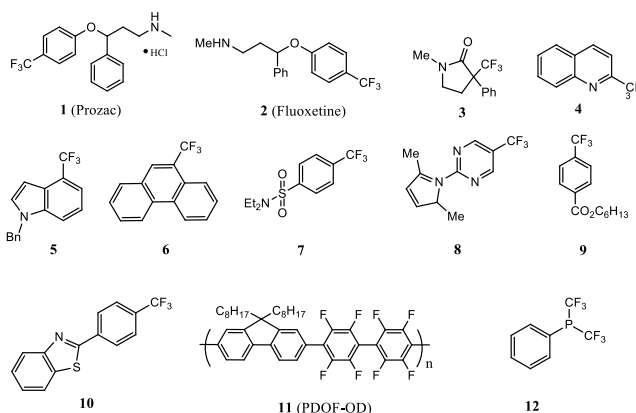
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1. Introduction

Incorporation of trifluoromethyl (CF₃) group on different types of organic molecules is a very important aspect, as these substrates are used in the development of pharmaceuticals [1-4] and agro-products [5-7]. These fluorinated materials help the stability of drugs [8] and lipophilicity [9,10]. So, it is important to have a diverse number of trifluoromethyl containing target molecules [11-14] and in this way, researchers are trying to continuously develop cheap and easily fabricable trifluoromethyl reagents (Scheme 1). Already some efficient methods are being used to synthesize trifluoromethyl containing substrates such as Ruppert-Prakash (TMSCF₃) [15], Togni reagent [16], Umemoto reagents [17], and Langlois reagent (CF₃SO₂Na) [18]. In these methods, trifluoromethyl either acts as electrophile [19], nucleophile [20] or as free radical [21-23].



Scheme 1. Examples of fluorinated compounds [1,3,9,11,32,52,73] and a fluorinated polymer [27].

It is worth mentioning that incorporating trifluoromethyl (CF_3) on organic molecules changes their properties and, in this way, fluorinated substrates are very important for the material's chemistry [24-26] for designing some smart materials such as semiconductor in organic light-emitting diode (OLED) [27] and organic field-effect transistor (OFET) [28]. It is also well known that handling fluorinated materials need extra precaution since they produce toxic chemicals [29] during chemical reaction with substrates. That is why there is still a big challenge working with fluorinated reagents [30]. Further, current trifluoromethylating reagents have some limitations such as toxicity, moisture sensitivity, and explosiveness [31]. Considering the following facts, researchers are trying to develop a facile method of synthesizing trifluoromethylated reagents and measuring their effectiveness for preparing trifluoromethylated substrates.

2. Aim of the Review

There is a wide variety of review articles for explaining the trifluoromethyl (CF_3) reagents for developing trifluoromethylated organic molecules. A few of them are concentrated on specific areas such as Umemoto's reagent [21], reactions in aqueous media [31], hypervalent iodine reagents [32], CF_3 -S transfer agents [33] and photolytic reactions [34]. Further, a few reviews have been discussed fluorine effect on chemical reactions [35] and in some reviews, it is described some selective trifluoromethylated reactions [36-39]. Although, a good number of review articles are available, sometimes it is difficult to extract important ideas from the vast amount of discussion. Besides, it is not known any review article that summarized all available trifluoromethylated reagents with highlighting the specific type of substrates scopes where most of them concentrated on one specific reagent and its substrate scopes. That is why a short review incorporating all types of available reagents is very essential especially for young researchers for getting incite and developing new trifluoromethylated organic substrates. Considering this, here, the review has been concentrated on all types of the current development of trifluoromethyl (CF_3) reagents up to 2020 and depending on these reagents probable target products are being discussed. So, it is believed that the reader will find a summary of all efficient reagents with their suitability on different organic targets and further, this will help researchers to identify easily suitable reagents/methods during the synthesis of trifluoromethylated materials. Also, it is well known that although a lot of methods are available all methods are not good for organic synthesis due to their low yield. Hence, some selective methods are described in this review that will be helpful to identify effective methods to prepare a gram scale of substrates during organic synthesis since reaction yields are discussed along with substrate scopes. It will also be beneficial having incite of the area needs to develop further after reading this review (section 3.11.). The review discusses very briefly all types of trifluoromethylated reagents, which is a benefit of this review to readers.

3. Different Types of Methods

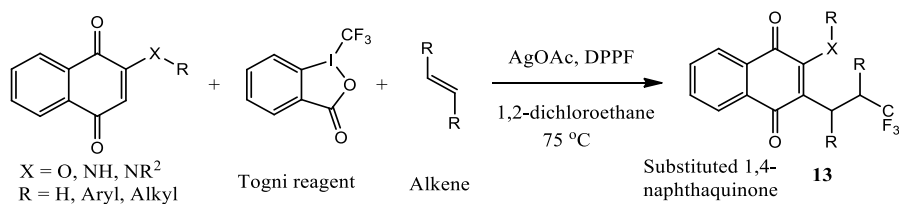
3.1. Silver salt catalysis

3.1.1. Light mediated trifluoromethylation using Ag-salts

It was used anatase TiO_2 powder, arene, silver trifluoroacetate, trifluoroacetic acid, and the solvent was used dry acetonitrile. The reaction was stirred under an inert condition with a 500 W Hg lamp for 24 h. This method easily helped to incorporate the trifluoromethyl (CF_3) group on aromatic systems. Even substituted aromatic systems (Ar-R , $\text{R} = \text{H}, \text{X}, \text{CH}_3, \text{CO}_2\text{R}, \text{CH}_2\text{NO}_2$, etc.) worked very smoothly. The demerit of the method is that reaction yields were mentioned moderate 10-50 % [40].

3.1.2. Silver catalyzed 1,4-naphthoquinone derivatives

In this method, trifluoromethyl (CF_3) substituted 26 different types of 1,4-naphthoquinone derivatives, which were prepared with 51-81% yield since the compounds may have therapeutic activity. The synthetic procedure involved a dry Schlenk line tube substituted 1,4-Naphthaquinone, Togni reagent, silver acetate, DPPF (1,1'-bis(diphenylphosphino)ferrocene), alkene (in 1,2-dichloroethane). Under the inert condition, the reaction was stirred at 75°C for 12 h. The unique significance of the method is that by changing the alkene and 1,4-naphthoquinone moiety, one can easily synthesize the expected trifluoromethyl (CF_3) substituted molecules [41] (Scheme 2).

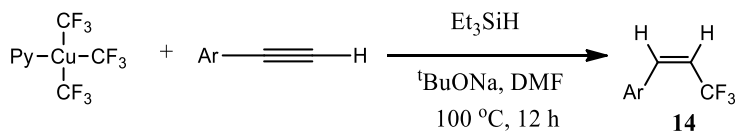


Scheme 2. Synthesis of substituted 1,4-naphthoquinone.

3.2. Copper catalysis

3.2.1. Hydrotrifluoromethylation of alkene

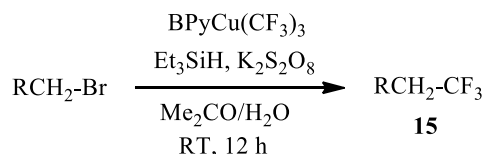
To a dry Schlenk line tube, silane and *t*-BuONa was added. The reaction was stirred at 100°C for 1 h in dry DMF. Later $(\text{Py})\text{Cu}(\text{CF}_3)_3$ and alkyne were added and again it was stirred for 12 h. In this way, trifluoromethylation happens by Cu catalyst [42] (Scheme 3).



Scheme 3. Trifluoromethylation of arylalkyne by the copper catalyst.

Synthesis of (Py)Cu(CF₃)₃ catalyst: It was stirred a mixture of CuI, AgF, pyridine, and TMSCF₃ in dry DMF for 21 h at room temperature under the inert condition to get the final catalyst (Py)Cu(CF₃)₃ [43].

Szabo *et al.* [44] used (PPh₃)₃CuCF₃ [45] to prepare allylic trifluoromethylated compounds. Grushin *et al.* [46] used CuCF₃ to introduce trifluoromethyl (CF₃) on aromatic diazonium salts. Li *et al.* [47,48] did trifluoromethylation of an alkyl halide with a yield of up to 98 % (Scheme 4).

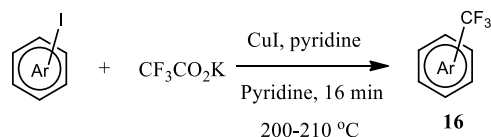


Scheme 4. Trifluoromethylation of alkyl halide.

Hartwig *et al.* used (Phen)CuR_f (R_f = CF₃, CF₂CF₃ etc.) for introducing trifluoromethyl (CF₃) on heteroaryl bromide [49] and aryl iodides [50]. Vici *et al.* [51] used LCu(I)-CF₃ for preparing different types of organic halides under the mild condition with a 99% yield.

3.2.2. Trifluoromethylation of aromatic and heteroaromatic systems

A successful method of incorporating trifluoromethyl was developed by Buchwald *et al.* [52] where it was used flow method. Shortly, CuI, pyridine, CF₃COOK, *N*-methylpyrrolidone (NMP), and 4-iodobiphenyl were injected in a preheated (200 °C) stainless steel tube reactor for 16 min. After isolating the target compound the yield was found 87 % (Scheme 5). It was mentioned that ester-, nitro-, amide-, sulfonamide- and chloro-substituted compounds gave good yield and were tolerated under flow temperature. The method was found also efficient for a variety of heterocyclic compounds such as indole, pyridines, pyrazine, pyrimidine, isoquinoline, quinoline, pyrrolopyridine, and imidazopyridine. Using this method two grams of trifluoromethylated product were isolated from 4-iodobenzoate.



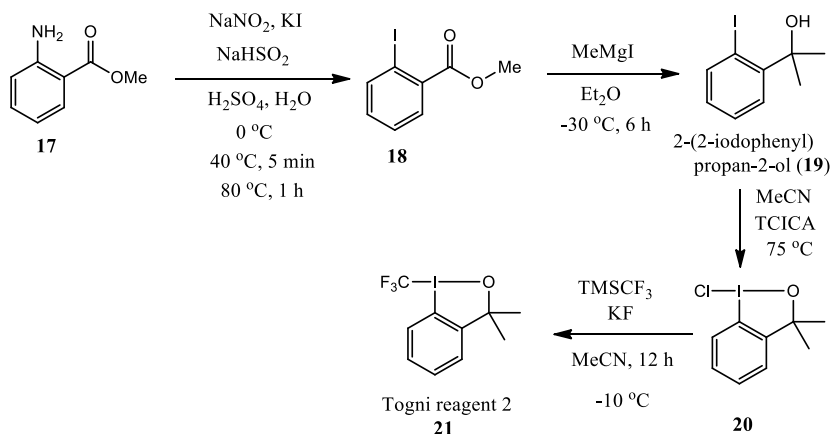
Scheme 5. Trifluoromethylation of aromatic systems.

3.3. Togni reagent

3.3.1. Synthesis of Togni reagents 2

A beaker was cooled in ice-salt mixtures with a magnetic stir bar at 0 °C. Next, it was added H₂SO₄ in the beaker. In this cooled acid, it was added methyl anthranilate (**17**) and

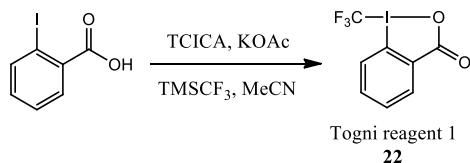
sodium nitrite that was dissolved in water. This mixture was heated (40 °C) and added sequentially potassium iodide, H₂SO₄, sodium hydrosulfite. Finally, methyl-2-iodobenzoate (**18**) is collected and purified (Scheme 3.5). This reaction mixture was added to dry ether with methylmagnesium iodide and the reaction was stirred at -30 °C for 6 h and 2-(2-iodophenyl)propan-2-ol (**19**) is formed and purified. This material was heated at 75 °C in dry acetonitrile and trichloroisocyanuric acid and 1-Chloro-3,3-dimethyl-1,2-benziodoxole (**20**) formed and purified. The chloro product was stirred with dry potassium fluoride in dry acetonitrile and added TMSCF₃ with stirring at -30 °C for 6 h. Later, it was stirred at -10 °C for 12 h leads to Togni reagent 2 (**21**) with 85-91 % yield [14] (Scheme 6).



Scheme 6. Synthesis of Togni reagent 2.

3.3.2. Synthesis of Togni reagents 1

One-pot synthesis of Togni reagent 1 was done from the reaction of 2-iodobenzoic acid, KOAc, and trichloroisocyanuric acid heating at 75 °C for 2 h in dry acetonitrile. Later, this was stirred with TMSCF₃ and gave Togni reagent 1 with a 75 % yield [14] (Scheme 7).



Scheme 7. One-pot synthesis of Togni reagent.

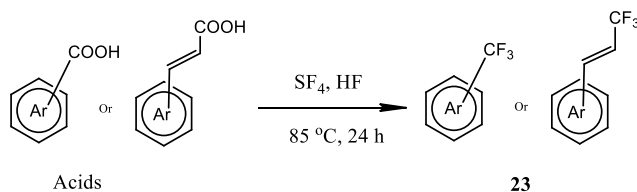
Using Togni reagents 1 and 2, different research groups prepared a large family of trifluoromethylated substrates. Togni group [53] prepared primary, secondary aryl- and alkylphosphines and lactams [9], Vincent *et al.* [54] prepared different types of alkenes, Shen group [55] used various types of boronic acids, Yu *et al.* [56] prepared trifluoromethylated dihydroisoquinolinones/indolines, He *et al.* [57] prepared

O-homoallyl benzimidates, and Gong *et al.* [58] introduced trifluoromethyl group on different types of alkyl iodides.

3.4. Decarbonylative reaction

3.4.1. Deoxyfluorination of aromatic acids

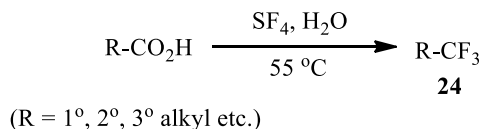
One of the efficient methods was using sulfur tetrafluoride, which was first introduced by Engelhardt group [59,60]. An acid (starting material) was placed in 500 mL autoclave, it was cooled by liquid nitrogen and anhydrous hydrofluoric acid (HF) was added. Next, SF₄ was added to the vessel and the mixture was gradually warmed to room temperature and heated at 85 °C for 24 h. Here, deoxyfluorination happened on heteroaromatic (substituted) and cinnamic acid into trifluoromethylated compounds (52-93 %) [61] (Scheme 8). Trifluoromethylation also went well in heterocyclic acids (45-91 %) having five-membered (45-88 %) and six-membered rings (54-89 %), quinolines (89 %), isoquinolines (84 %), pyrazole (87 %), aniline (55-84 %), piperidines (66-82 %) and amino acids (73-91 %). The good thing is that this method helps to prepare those substrates in gram scale.



Scheme 8. Deoxyfluorination of heteroaromatic and cinnamic acids.

3.4.2. Deoxyfluorination of aliphatic acids

Different types of aliphatic trifluoromethyl derivatives have been prepared from aliphatic acids almost as same as shown in section 3.4.1 (Scheme 9) [62]. The reactions went smoothly in gram scale for different types of primary, secondary, tertiary, and α -halogeno acids, cyclic amines, and α -amino acids with retaining stereo and absolute configuration of chiral centers. The method is developed by Engelhardt [60], Li [48], and MacMillan [63], however, the following method is better since it does not need liquid hydrofluoric acid (HF) and, also, chiral centers remain unaltered.

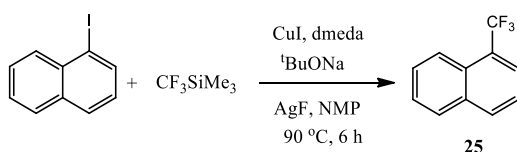


Scheme 9. Deoxyfluorination of aliphatic carboxylic acid.

3.5. Ruppert-Prakash reagents

3.5.1. Trifluoromethylation of aryl iodide

In a reaction vial, CuI, *t*-BuONa, and NMP (*N*-methylpyrrolidone) were stirred at room temperature for 10 min. Later, *N,N'*-dimethylenediamine was added to the above reaction mixture. After 2 min AgF and Me₃SiCF₃ were added to the reaction mixture. Fitted with a teflon screw cap, the reaction heated at 90 °C for 30 min. After cooling, a few more portions of Me₃SiCF₃ were added and, finally, the reaction was stirred for 5 h at 90 °C (Scheme 10). In this method, different types of iodoarenes were used and yields were noted 47-98 %. It is said that Cu and Ag both played a role in this type of transformation.



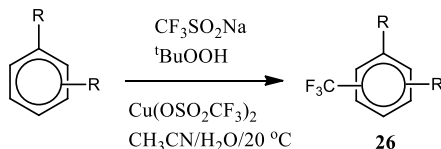
Scheme 10. Trifluoromethylation of iodoarene.

Similarly, using the reagent Me₃SiCF₃, some other types of organic compounds such as isoindolinones, isoquinolinones, 2-pyridinones, and other heterocycles were prepared [64]. Browne's group [65] also transformed C-N to C-CF₃ through Sandmeyer reaction using this reagent (Me₃SiCF₃).

3.6. Langlois reagent

3.6.1. Sodium trifluoromethanesulfinate as CF₃ source

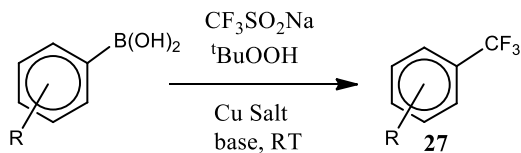
In this method, sodium trifluoromethanesulfinate is used and tert-butyl hydroperoxide is used as a source of oxidizer. A catalytic amount of Cu(OSO₂CF₃)₂ was used and the reaction was done in acetonitrile at 20 °C. This reagent helps to introduce CF₃ on a wide variety of substituted aromatic systems (Scheme 11) with the highest yield up to 90 % [18].



Scheme 11. Trifluoromethylation of aromatic compounds by using Langlois reagent.

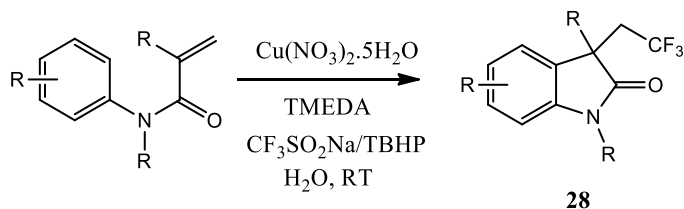
A big advantage of this reagent is that it is very cheap compare to other available reagents and triflinate salt is air stable. Triflinate salt is also easy to prepare by using bromotrifluoromethane and sodiumdithionite or zinc/SO₂. Later, different research groups

prepared different types of trifluoromethylated compounds by using this reagent. Wang's group [66] prepared different types of trifluoromethylated oxindoles from activated alkenes with a 94 % yield where he used $K_2S_2O_8$ as oxidant (Scheme 12).



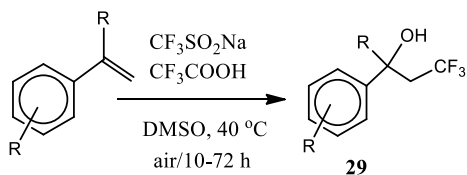
Scheme 12. Langlois reagent for trifluoromethylation of arylboronic acids.

Like Wang's group, Lipshutz *et al.* [67] prepared different types of oxindoles by using Langlois reagent, Cu salt, tetramethylethylenediamine (TMEDA), and tert-butyl hydroperoxide (TBHP) in water with a yield up to 87 % (Scheme 13).



Scheme 13. Copper-catalyzed trifluoromethylation of oxindoles by using Langlois reagent.

Sanford group [68] used *t*-BuOOH, Langlois reagent, and different types of arylboronic acids. It is also noted that aryl boronic acids having electron-donating groups such as alkyl, alkoxy, and phenoxy, and the presence of $NaHCO_3$ and $(MeCN)_4CuPF_6$ lead to excellent yield. Liu's group [69] studied alkene in dimethyl sulfoxide (DMSO) and found a good yield of up to 95 % (Scheme 14).



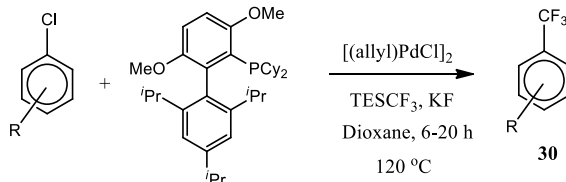
Scheme 14. Hydroxytrifluoromethylation of an alkene by Langlois reagent.

3.7. Metal complexes in catalysis

3.7.1. Pd catalyzed reaction

Different types of palladium complexes were used for the preparation of trifluoromethylated compounds. These types of metal complexes are only suitable to get $Ar-CF_3$ complexes. For example, Sanford *et al.* [70] used $(L)_2Pd^{II}(Ar)(CF_3)$ and $(dtbpy)Pd^{II}(Aryl)(CF_3)$ [71] to prepare $Ar-CF_3$ and Romashov *et al.* [72] used

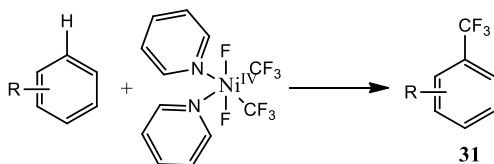
[(Xantphos)Pd(CF₃)(Ph)] for preparation of Ar-CF₃. It is also noted that Buchwald *et al.* [73] prepared trifluoromethylated aromatic compounds using palladium complex as a catalyst (Pd(0)-Pd(II)), where heating Ar-Cl, TESCf₃ (triethylsilyl) and KF in dioxane at 120 °C gave an excellent yield (up to 80 %) (Scheme 15).



Scheme 15. Palladium-catalyzed trifluoromethylation of aromatic systems.

3.7.2. Ni catalyzed reaction

Sanford *et al.* prepared Ni^{II}-CF₃ [74] and Ni^{IV}-CF₃ [75] complexes to introduce the trifluoromethyl (CF₃) group on arene and heteroarenes. Nebra *et al.* [76] used [(Py)₂Ni^{IV}F₂(CF₃)₂] for the C-H functionalization of aromatic compounds up to a 94 % yield (Scheme 16).

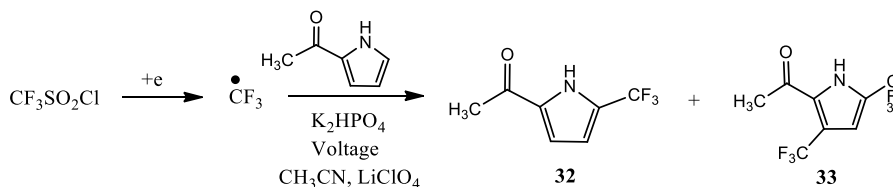


Scheme 16. Nickel catalyzed trifluoromethylation of aromatic systems.

3.8. Electrochemical method

3.8.1. Electrosynthesis of arenes and heteroarenes

Alternating current electrolysis (ACE) is a technique where an alternating voltage ($\pm v$) is applied to push the redox transformations. In an electrochemical method, first, triflyl chloride generates trifluoromethyl (CF₃) radical (Scheme 17) under negative electrode potential and, next, this trifluoromethyl (CF₃) reacts with the aromatic system (2-acetylpyrrole) and forms a radical intermediate. When the voltage is reversed, the intermediate is oxidized to allylic cation, and subsequent deprotonation results in the final product. Instead of paired electrolysis, the ACE method gives a better yield of up to 84% [77]. This method successfully prepares trifluoromethylated pyrroles, arenes, furans, thiophenes, and imidazole with moderate to high yield. Since the intermediate involves the loss of aromaticity, electrosynthesis gave a low yield.

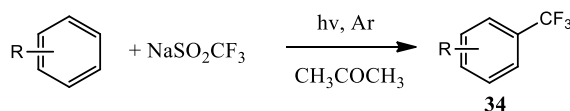


Scheme 17. Electrosynthesis of aromatic arenes.

Studer's research group [78] has also published an electrochemical method for the synthesis of trifluoromethylated phenanthridine by using Togni reagent with the highest yield up to 77 %.

3.9. Light-driven

In the light-driven method, it uses light and some photocatalyst, such as Iridium (III), $[\text{Ru}(\text{bpy})_3]^{2+}$. In addition, as a source of trifluoromethyl group Togni reagent [79], Umemoto reagent [80], Ruppert-Prakash [81], CF_3I [82], $\text{CF}_3\text{SO}_2\text{Cl}$ [83], $\text{CF}_3\text{SO}_2\text{Na}$ [84], and $(\text{CF}_3\text{SO}_2)_2\text{Zn}$ [85] are used. In this method different types of trifluoromethylated alkene [86-89], azides [90], aromatic compounds [91-92] (scheme 3.9.1), α , β -unsaturated carboxylic acids [93], and benzimidazoles [94] were prepared. The advantage of the photochemical method is that it is not expensive [91] and toxic metal catalyst is not used in some special cases (Scheme 18) since most of the pharmaceutical industry needs substrates free of metals. In some cases, the removal of metal is very tough and induces extra cost of substrates.

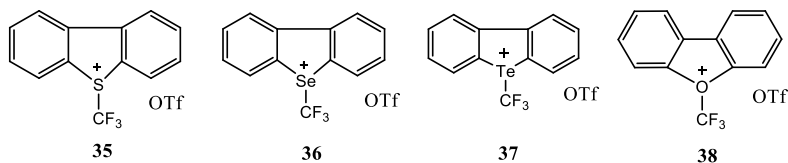


Scheme 18. Trifluoromethylation on aromatic compounds.

3.10. Umemoto reagent

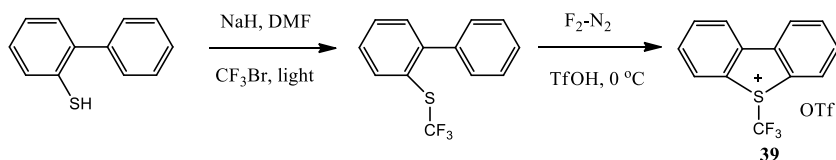
3.10.1. Types of Umemoto reagents

Umemoto and coworkers [95,96] have developed some reagents (Scheme 19) that are used to incorporate trifluoromethyl (CF_3) on different types of aromatic systems as an electrophile. *S*-(trifluoromethyl)dibenzothiophenium triflate (**35**) is used in synthesis due to its better reactivity. This reagent (**35**) has a better yield during synthesis than others.



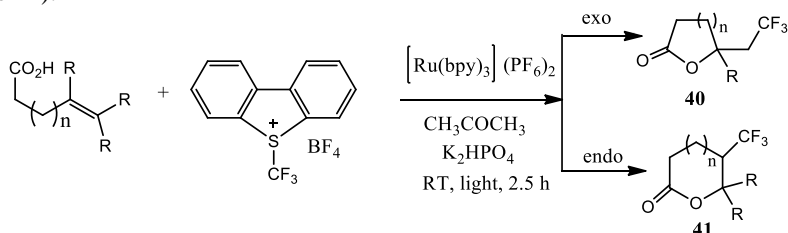
Scheme 19. Umemoto reagents.

2-mercaptobiphenyl was placed in dry dimethylformamide (DMF) and cooled in an ice bath. It was added NaH, and when hydrogen gas evolution is ceased, it was added CF_3Br gas and irradiated by Hg lamp for 2 h. Finally, an oily product was formed (82 %). Next, F_2 and N_2 were introduced (1:9 mixture) with the addition of TfOH in CCl_3F at 0°C . The reaction warmed to room temperature and after the addition of Et_2O , white precipitate of *S*-(trifluoromethyl)dibenzothiophenium triflate (**35**) (Scheme 20) was formed (83 % yield).



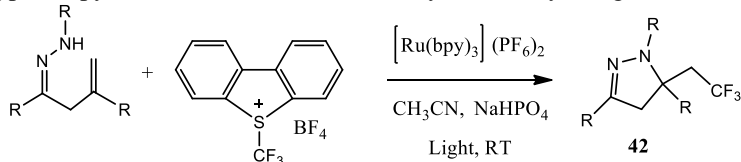
Scheme 20. Synthesis of *S*-(trifluoromethyl)dibenzothiophenium triflate.

Akita *et al.* [97] prepared different types of lactones by using Umemoto reagent. In this method, it was found that bases K_2HPO_4 or K_2CO_3 helped in reaction yield, and $[\text{Ru}(\text{bpy})_3](\text{PF}_6)_2$ was used as a photoredox catalyst. The yield was found in 28-85 % (Scheme 21).

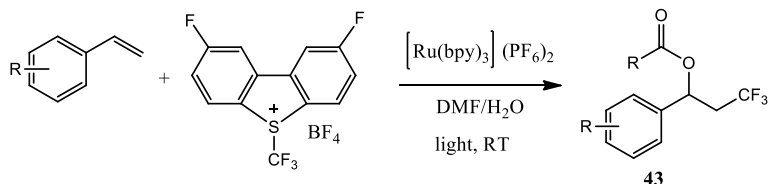


Scheme 21. Synthesis of trifluoromethylated lactone by using Umemoto reagent.

Xiao *et al.* [98] (Scheme 22) and She *et al.* [99] (Scheme 23) research groups prepared different types of pyrazolines, isoxazolines, and arylalkenes by using Umemoto reagents.



Scheme 22. Synthesis of β,γ -unsaturated hydrazones.



Scheme 23. Photocatalytic trifluoromethylation of arylalkenes.

Gouverneur *et al.* [100] focused on inactivated alkene with Ru(bpy)₃Cl₂ as photocatalyst in MeOH and light-driven product with a moderate yield of 64 %. CF₃H is added to alkene where Umemoto reagent acts as trifluoromethyl CF₃ donor and methanol as hydrogen donor with maintaining regioselectivity.

3.11. Future direction

Trifluoromethylating reagents still have some problems like air and moisture sensitivity. It is also noted that a few reagents are very expensive. Besides, one reagent is not effective for all types of substrates, like trifluoromethylation of alkene, amine, amide, arene, heteroarene, etc. So, a common reagent that will be very cheap, stable, and effective for all types of substrates may open a new window for the development of trifluoromethylated substrates. Currently, non-metallic reagents are very important for developing new drugs. During the development of new materials, it may consider following solvents such as MeCN, DMF, DMSO. It is seen in literature that a few groups did the reaction in MeOH and used water as a solvent. Since toxic chemicals may generate during the reaction, a facile route is still necessary to develop in the future.

4. Conclusion

This review is illustrating clearly some important trifluoromethylated reagents and their effectiveness for different types of substrates. Although a lot of reviews exist, this review will be very effective for getting knowledge about the CF₃ reagents, as here everything is mentioned very briefly to make it interesting to the reader. Additionally, it will be very helpful as a practical guide if anyone wants to develop some new materials either reagent or substrates. The synthetic methods of the reagents are discussed citing their original articles as reference.

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